

化粧品禁止使用成分表

編號	成分名	CAS No.
1	Mercury and its compounds(化粧品防腐劑成分名稱及使用限制表中另有規定者除外) 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含不純物重金屬汞之殘留量，不得超過 1ppm。	7439-97-6
2	4-Benzyloxyphenol and 4-ethoxyphenol	103-16-2/ 622-62-8
3	Bithionol	97-18-7
4	Pilocarpine and its salts	92-13-7
5	Halogeno-salicylanilide	-
6	Boric acid(口腔製劑另有規定者除外)	10043-35-3/ 11113-50-1
7	Sodium perborate(口腔製劑另有規定者除外)	7632-04-4
8	Sodium borate 含微量 Sodium borate 用以乳化 Beeswax 及 Bleached Beeswax 者，不在此限，惟其含量不得超過 0.76%。	1330-43-4
9	Chlorofluorocarbons	-
10	3'-Ethyl-5',6',7',8'-tetrahydro-5',5',8',8'-tetramethyl-2'- acetoneaphthone or 7-acetyl-6-ethyl-1,1,4,4-tetramethyl-1,2,3,4-tetrahydronaphthalen (AETT; Versalide)	88-29-9
11	Cells, tissues or products of human origin	-
12	Hydroxy-8-quinoline and its sulphate 使用於染髮、燙髮產品中,用作 Hydrogen peroxide 之安定劑不得超過 0.03%(以 base 計)	148-24-3/ 134-31-6
13	Dichloromethane	75-09-2
14	4-tert-Butyl-3-methoxy-2,6-dinitrotoluene (Musk ambrette)	83-66-9
15	6-Methylcoumarin(口腔製劑另有規定者除外)	92-48-8
16	Vinyl chloride monomer	75-01-4
17	2,2'-Dihydroxy-3,3',5,5',6,6'-hexachlorodiphenylmethane (Hexachlorophene (INN))	70-30-4
18	Tretinoin (INN) (retinoic acid and its salts)	302-79-4
19	4-Amino-2-nitrophenol	119-34-6
20	Antimony and its compounds	7440-36-0
21	Arsenic and its compounds 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含不純物重金屬砷之殘留量，不得超過 3ppm。	7440-38-2
22	Cadmium and its compounds 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含不純物重金屬鎘之殘留量，不得超過 5ppm。	7440-43-9
23	Cantharidine	56-25-7
24	Chloroacetamide	79-07-2
25	Chloroform	67-66-3

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26	Chromium; Chromic acid and its salts(化粧品色素成分使用限制表中另有規定者除外)	7440-47-3
27	Dibutyl phthalate 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之總殘留量，不得超過 100ppm。	84-74-2
28	Dichlorophen	97-23-4
29	2,6-Dimethyl-1,3-dioxan-4-yl acetate (Dimethoxane)	828-00-2
30	Dioxane 化粧品於製造過程中，如因所需使用之原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含 1,4-二氧六圓之殘留量，不得超過 100ppm。	123-91-1
31	2-Ethoxyethanol and its acetate (2-Ethoxyethyl acetate)	110-80-5/ 111-15-9
32	4-Ethoxy-m-phenylenediamine and its salts	67801-06-3/ 5862-77-1/ 68015-98-5/ 6219-69-8
33	Fluorine compounds (as Inorganic compounds) (口腔製劑另有規定者除外)	
34	Formaldehyde (Formalin) (1)化粧品中使用 DMDM Hydantoin、Imidazolidinyl urea、Quaterium 15、Benzylhemiformal、5-Bromo-5-nitro-1,3-dioxane、Bronopol、Methenamine、Sodium hydroxymethylglycinate、Diazolidinyl urea 成分作為防腐劑時，其總釋出之 Free formaldehyde 量，不得超過 1000ppm。 (2)未添加 DMDM Hydantoin、Imidazolidinyl urea、Quaterium-15、DiaZolidinyl urea、Hexamethylenetetramine、Benzylhemiformal、5-Bromo-5-nitro-1,3-dioxane、Bronopol 及 Sodium hydroxymethylglycinate 等防腐劑成分，如於製造過程中，因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含游離甲醛 (Free formaldehyde) 之殘留量，不得超過 75ppm。	50-00-0
35	HC Blue No.1 (2,2'-([4-(Methylamino)-3-nitrophenyl]imino)bis(ethanol))	2784-94-3
36	Hydrogen peroxide 使用於染髮、燙髮及牙齒美白產品當氧化劑除外。	7722-84-1
37	p-Hydroxyanisol (4-Methoxyphenol ; Hydroquinone monomethyl ether ; Monobenzene)	150-76-5
38	Lead and its compounds 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含不純物重金屬鉛之殘留量，不得超過 10ppm。	7439-92-1
39	Local anesthetics (e.g.Lidocaine、Procaine)	-
40	1-Methoxy-2,4-diaminobenzene (2,4-Diaminoanisole; CI 76050) and its salts	615-05-4
41	1-Methoxy-2,5-diaminobenzene (2,5-Diaminoanisole) and its salts	5307-02-8
42	4-Methyl-m-phenylenediamine (Toluene-2,4-diamine) and its salts	95-80-7
43	Methyl methacrylate	80-62-6
44	Nitrofurantoin (INN)	67-20-9
45	Nitrosamines e.g. Dimethylnitrosoamine; Nitrosodipropylamine; 2,2'-Nitrosoimino)bisethanol; Nitrosamine diethyl(Diethylamine, N-nitroso-)	62-75-9/ 621-64-7/ 1116-54-7/

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		55-18-5
46	Oestrogens	-
47	o-Phenylenediamine and its salts	95-54-5
48	p-Phenylenediamine(使用於染髮產品除外)	106-50-3
49	Potassium bromate	7758-01-2
50	Pregnanediol	80-92-2
51	Pregnenolone acetate	1778-02-5
52	Pyrocatechol (Catechol)	120-80-9
53	Pyrogallol	87-66-1
54	Selenium and its compounds(使用於髮類產品之 Selenium disulfide 除外)	7782-49-2
55	Strontium compounds(口腔製劑另有規定者除外)	7440-24-6
56	Sulphonamides (sulphanilamide and its derivatives obtained by substitution of one or more H-atoms of the -NH ₂ groups) and their salts	-
57	2-Methyl-m-phenylenediamine (Toluene-2,6-diamine)	823-40-5
58	Trichloroacetic acid	76-03-9
59	3-Imidazol-4-ylacrylic acid (Urocanic acid) and its ethyl ester	104-98-3/ 27538-35-8
60	Zirconium and its compounds 不得使用於噴霧類化粧品； 惟用作色素之 zirconium lakes, salts 除外。	7440-67-7
61	Aconitum napellus L. (leaves, roots and galenical preparations)	84603-50-9
62	Adonis vernalis L. and its preparations	84649-73-0
63	Ammi majus L. and its galenical preparations	90320-46-0
64	Anamirta cocculus L. (fruit)	-
65	Apocynum cannabinum L. and its preparations	84603-51-0
66	Aristolochic acid and its salts; Aristolochia spp. and their preparations	475-80-9/ 313-67-7/ 15918-62-4
67	Atropa belladonna L. and its preparations	8007-93-0
68	Cantharides, Cantharis vesicatoria Cantharides tincture 用於髮類產品之規定，應參考化粧品成分使用限制表。	92457-17-5
69	Chenopodium ambrosioides L. (essential oil)	8006-99-3
70	Claviceps purpurea Tul., its alkaloids and galenical preparations	84775-56-4
71	Colchicum autumnale L. and its galenical preparations	84696-03-7
72	Conium maculatum L. (fruit, powder, galenical preparations)	85116-75-2
73	Croton tiglium L. (oil)	8001-28-3
74	Datura stramonium L. and its galenical preparations	84696-08-2
75	Digitaline and all heterosides of Digitalis purpurea L.	752-61-4
76	Hyoscyamus niger L. (leaves, seeds, powder and galenical preparations)	84603-65-6

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77	Ipecacuanha (Cephaelis ipecacuanha Brot. and related species) (roots, powder and galenical preparations)	8012-96-2
78	Juniperus sabina L. (leaves, essential oil and galenical preparations)	90046-04-1
79	Oil from the seeds of Laurus nobilis L.	84603-73-6
80	Lobelia inflata L. and its galenical preparations	84696-23-1
81	Physostigma venenosum Balf.	89958-15-6
82	Phytolacca spp. and their preparations	60820-94-2/ 65497-07-6
83	Pilocarpus jaborandi Holmes and its galenical preparations	84696-42-4
84	Prunus laurocerasus L. (cherry laurel water)	89997-54-6
85	Pyrethrum album L. and its galenical preparations	-
86	Schoenocaulon officinale Lind (seeds and galenical preparations)	84604-18-2
87	Solanum nigrum L. and its galenical preparations	84929-77-1
88	Strophantus species and their galenical preparations	-
89	Strychnos species and their galenical preparations	-
90	Thevetia neriifolia Juss., glycoside extract	90147-54-9
91	Urginea scilla Steinh. and its galenical preparations	84650-62-4
92	Veratrum spp. and their preparations	90131-91-2
93	Arsenolite (信石)	-
94	Daphnis Genkwa Flos (芫花)	-
95	Daturae Flos (洋金花)	-
96	Euphorbiae Pallasii Radix (白狼毒)	-
97	Euphorbiae Kansui Radix (甘遂)	-
98	Hirudo (水蛭)	-
99	Hyoscyami Semen (天仙子)	-
100	Impatientis Semen (急性子)	-
101	Knoxiae Radix (紅大戟)	-
102	Pharbitidis Semen (牽牛子)	-
103	Tabanus (虻蟲)	-
104	Acrolein	107-02-8
105	Acrylamide 如化粧品中使用含 Polyacrylamides 及其相關聚合物成分之原料時，則其最終製品中所含 Acrylamide 之殘留量不得超過 0.1ppm；對於使用後須沖洗掉或非駐留身體肌膚用之化粧品，其最終製品中所含 Acrylamide 之殘留量不得超過 0.5ppm。	79-06-1
106	Acrylonitrile	107-13-1
107	Aldrin (ISO)	309-00-2
108	Allyl alcohol	107-18-6
109	Biphenyl-4-ylamine (4-Aminobiphenyl) and its salts	92-67-1
110	Aniline, its salts and its halogenated and sulphonated derivatives	62-53-3

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111	Asbestos 化粧品及其滑石粉(Talc)原料，依國際間公認之檢驗方法，不得檢出石綿成分。	1332-21-4
112	Benzidine/ Benzidine acetate/ Benzidine sulfate/ Benzidine dihydrochloride/ Benzidine dihydrofluoride/ Benzidine perchlorate/ Benzidine perchlorate/ Benzidine diperchlorate	92-87-5/ 36341-27-2/ 531-86-2/ 531-85-1/ 41766-73-8/ 29806-76-6/ 38668-12-1/ 41195-21-5
113	Benzene	71-43-2
114	Beryllium and its compounds	7440-41-7
115	Oxybis[chloromethane], bis (Chloromethyl) ether	542-88-1
116	α -Bromobenzyl cyanide	5798-79-8
117	1,3-Butadiene	106-99-0
118	Captafol	2425-06-1
119	N-(Trichloromethylthio)-4-cyclohexene-1,2-dicarboximide(Captan(ISO))	133-06-2
120	Chlordane, pur	57-74-9
121	Chlorine	7782-50-5
122	α -Chloroacetophenone (w-Chloroacetophenone)	532-27-4
123	Chlorobenzilate	510-15-6
124	Chloromethyl methyl ether	107-30-2
125	p-Chloro-o-toluidine	95-69-2
126	Cyanazine	21725-46-2
127	Sodium cyanide/ Potassium cyanide/ Silver cyanide/ Copper(I) cyanide/ Copper(I) potassium cyanide/ Cadmium cyanide/ Zinc cyanide/ Copper(II) cyanide/ Copper Sodium cyanide	143-33-9/ 151-50-8/ 506-64-9/ 544-92-3/ 13682-73-0/ 542-83-6/ 557-21-1/ 14763-77-0/ 14264-31-4
128	Cyhexatin	13121-70-5
129	1,2-Dibromo-3-chloropropane	96-12-8
130	3,3'-Dichlorobenzidine	91-94-1
131	Clofenotane (INN); DDT (ISO)	50-29-3
132	Dieldrin	60-57-1

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133	Dimethylcarbamoyl chloride	79-44-7
134	Dimethylformamide (N,N-Dimethylformamide)	68-12-2
135	Dimethyl sulfate	77-78-1
136	4,6-Dinitro-o-cresol (DNOC(ISO))	534-52-1
137	Dinitrophenol isomers	51-28-5/ 329-71-5/ 573-56-8/ 25550-58-7
138	Dinoseb, its salts and esters	88-85-7
139	1,2-Diphenylhydrazine	122-66-7
140	(1R,4S,5R,8S)-1,2,3,4,10,10-Hexachloro-6,7-epoxy1,4,4a,5,6,7,8,8a-octahydro-1,4:5,8-dimethano-naphthalene (endrin(ISO))	72-20-8
141	1-Chloro-2,3-epoxypropane (Epichlorohydrin)	106-89-8
142	1,2-Dibromoethane	106-93-4
143	Aziridine	151-56-4
144	2-Methoxyethanol and its acetate (2-Methoxyethyl acetate)	109-86-4/ 110-49-6
145	Ethylene oxide	75-21-8
146	Diethyl sulfate	64-67-5
147	N-(Trichloromethylthio)phthalimide (Folpet(ISO))	133-07-3
148	Heptachlor	76-44-8
149	Hexachlorocyclohexane	319-84-6/ 319-85-7/ 319-86-8 6108-10-7
150	Hexamethylphosphoric triamide	680-31-9
151	Hydrogen cyanide and its salts	74-90-8
152	Leptophos	21609-90-5
153	1,2,3,4,5,6-Hexachlorocyclohexane (BHC(ISO))	58-89-9
154	4,4'-Methylene-bis(2-chloroaniline)	101-14-4
155	Methyl hydrazine	60-34-4
156	Methyl isocyanate	624-83-9
157	Monofluoroacetamide	640-19-7
158	1-and 2-Naphthylamines and their salts	91-59-8/ 134-32-7
159	Tetracarbonylnickel	13463-39-3
160	4-Nitrobiphenyl	92-93-3
161	Nitrofen	1836-75-5

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162	N-Nitroso-N-methylurea	684-93-5
163	Pentachlorophenol and its alkali salts	87-86-5/ 131-52-2/ 7778- 73-6
164	Phosgene	75-44-5
165	Phosphine	7803-51-2
166	Phosphorus trichloride	7719-12-2
167	Phthalic anhydride	85-44-9
168	Polychlorinated biphenyls	1336-36-3
169	Propargyl alcohol	107-19-7
170	2-Methylaziridine	75-55-8
171	(Epoxyethyl)benzene (Styrene oxide)	96-09-3
172	Tetrachloroethylene	127-18-4
173	Thiosemicarbazide (1-amino-2-thiourea)	79-19-6
174	m-Tolylidene diisocyanate (Toluene diisocyanate)	26471-62-5
175	4-Methyl-m-phenylene diisocyanate (Toluene 2,4- diisocyanate)	584-84-9
176	Trichloroethylene	79-01-6
177	α,α,α -Trichlorotoluene	98-07-7
178	2,4,5-Trichlorophenol	95-95-4
179	2,4,6-Trichlorophenol	88-06-2
180	1,2,3-Trichloropropane	96-18-4
181	Trinickel disulfide	12035-72-2
182	Tris(2,3-dibromopropyl)phosphate	126-72-7
183	Bromoethylene (Vinyl bromide)	593-60-2
184	Acetonitrile	75-05-8
185	Anthracene oil	120-12-7
186	Benzyl butyl phthalate (BBP) 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之殘留量，不得超過 100ppm。	85-68-7
187	Bis-(2-chloro-1-methylethyl) ether	108-60-1
188	bis(2-Ethylhexyl) phthalate (Diethylhexyl phthalate) 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之殘留量，不得超過 100ppm。	117-81-7
189	Bis(2-methoxyethyl) phthalate (Dimethoxyethyl phthalate) 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之殘留量，不得超過 100ppm。	117-82-8
190	Bromoform (Tribromomethane)	75-25-2

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191	Carbon disulfide	75-15-0
192	Carbon tetrachloride	56-23-5
193	Chlorobenzene	108-90-7
194	Chloroethane (Ethyl chloride)	75-00-3
195	Chloromethane (Methyl chloride)	74-87-3
196	Crotonaldehyde	4170-30-3
197	Daminozide	1596-84-5
198	Dibenzofuran	132-64-9
199	Dibromomethane (Methylenebromide)	74-95-3
200	1,2-Dichloropropane	78-87-5
201	1,3-Dichlorobenzene	541-73-1
202	1,2-Benzenedicarboxylic acid, dipentylester, branched and linear; n-Pentyl-isopentylphthalate; di-n-Pentyl phthalate; Diisopentylphthalate 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之殘留量，不得超過 100ppm。	605-50-5/ 84777-06-0/ 131-18-0
203	3,3'-Dimethoxybenzidine (ortho-Dianisidine) and its salts	119-90-4
204	4,4'-Bi-o-toluidine (ortho-Tolidine)	119-93-7
205	Diphenylamine	122-39-4
206	Fenchlorphos	299-84-3
207	Hexachloro-1,3-butadiene	87-68-3
208	Hexachlorobenzene	118-74-1
209	Hexachloroethane	67-72-1
210	Hexachloronaphthalene	1335-87-1
211	2,4-Hexadienal	142-83-6
212	Hydrazine, its derivatives and their salts	302-01-2
213	4,4'-Methylenedianiline	101-77-9
214	Iodomethane (Methyl iodide)	74-88-4
215	Naphthalene	91-20-3
216	Nitrobenzene	98-95-3
217	o-Aminotoluene/ m-Aminotoluene/ p-Aminotoluene	95-53-4/ 108-44-1/ 106-49-0
218	Octachloronaphthalene	2234-13-1
219	o-Dichlorobenzene (1,2-Dichloro benzene)	95-50-1
220	Pentachloronitrobenzene	82-68-8
221	Propiolactone	57-57-8
222	Pyridine	110-86-1
223	Thiourea (Thiocarbamide)	62-56-6

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224	Toxaphene	8001-35-2
225	Tributyltin oxide (Bis(tributyltin)oxide)	56-35-9
226	1,2,4-Trichlorobenzene	120-82-1
227	Fentin hydroxide	76-87-9
228	Areca catechu L.(檳榔)	-
229	Asarum blumei Duch.(細辛)	-
230	Brucea javanica (L.) Merr.(鴨膽子)	-
231	Bufo melanostictus (蟾酥)	-
232	Clematis chinensis Osbeck (威靈仙)	-
233	Convallaria majalis L. (Convallaria keiskei Miq.) (鈴蘭)	-
234	Coriaria sinica Maxim. (馬桑)	-
235	Derris trifoliata Lour. (魚藤)	-
236	EphedraTourn. ex L. (Ephedraceae). (麻黃)	-
237	Euphorbia lathyris L. (續隨子；千金子)	-
238	Illicium lanceolatum A.C. Smith (莽草)	-
239	Lycoris radiata Herb. (石蒜)	-
240	Nerium indicum Mill. (夾竹桃)	-
241	Phytolacca acinosa Roxb. (商陸)	-
242	Pinellia ternata (Thunb.) Breit. (半夏)	-
243	Rhododendron molle G. Don (羊躑躅；鬧羊花)	-
244	Sinapis alba L. (芥子)	-
245	Lead acetate, it trihydrate and derivatives	6080-56-4
246	Acid Orange 24 (CI 20170)	1320-07-6
247	Acid Red 73 (CI 27290)	5413-75-2
248	4-Aminoazobenzene	60-09-3
249	4-o-Tolylazo-o-toluidine	97-56-3
250	5-Amino-4-fluoro-2-methylphenol sulfate	163183-01-5
251	2-Aminomethyl-p-aminophenol and its HCl salt	79352-72-0
252	o-Anisidine	90-04-0
253	2,6-Bis(2-Hydroxyethoxy)-3,5-pyridinediamine and its HCl salt	117907-42-3
254	Bis(2-Methoxyethyl) ether (Dimethoxydiglycol)	111-96-6
255	4-Chloro-2-aminophenol	95-85-2
256	4-Chloroaniline	106-47-8
257	Chromated Copper Arsenate	37337-13-6
258	Cobalt dichloride	7646-79-9
259	N-Cyclopentyl-m-aminophenol	104903-49-3
260	3,4-Diaminobenzoic acid	619-05-6

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261	2,4-Diaminodiphenylamine	136-17-4
262	4,5-Diamino-1-((4-chlorophenyl)methyl)-1H-pyrazole sulfate	163183-00-4
263	2,4-Diamino-5-methylphenetol and its HCl salt	113715-25-6
264	4,5-Diamino-1-methylpyrazole and its HCl salt	20055-01-0/ 21616-59-1
265	N,N-Diethyl-m-aminophenol	91-68-9/ 68239-84-9
266	N,N-Dimethyl-2,6-pyridinediamine and its HCl salt	-
267	4-Hydroxyindole	2380-94-1
268	2-Methoxymethyl-p-aminophenol and its HCl salt	29785-47-5/ 135043-65-1
269	6-Methoxy-2,3-pyridinediamine and its HCl salt	94166-62-8
270	4-Methoxytoluene-2,5-diamine and its HCl salt	56496-88-9
271	6-Methoxy-m-toluidine (p-Cresidine)	120-71-8
272	N-Methylacetamide	79-16-3
273	4,4'-Methylenedi-o-toluidine	838-88-0
274	N-(2-Methoxyethyl)-p-phenylenediamine and its HCl salt	72584-59-9/ 66566-48-1
275	1,7-Naphthalenediol	575-38-2
276	2,3-Naphthalenediol	92-44-4
277	5-Nitro-o-toluidine/ 5-Nitro-o-toluidine hydrochloride	99-55-8/ 51085-52-0
278	Diphenylether; octabromo derivate	32536-52-0
279	4,4'-Oxydianiline (p-Aminophenyl ether) and its salts	101-80-4
280	Pentabromodiphenyl ether	32534-81-9
281	Solvent Red 1 (CI 12150)	1229-55-6
282	4,4'-Thiodianiline and its salts	139-65-1
283	2,4,5-Trimethylaniline/ 2,4,5-Trimethylaniline hydrochloride	137-17-7/ 21436-97-5
284	Di-n-octyl phthalate 化粧品於製造過程中，如因所需使用原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含鄰苯二甲酸酯類成分之殘留量，不得超過 100ppm。	117-84-0
285	6-Amino-o-cresol and its salts	17672-22-9
286	2-Amino-3-nitrophenol and its salts	603-85-0
287	[4-[[4-Anilino-1-naphthyl][4-(dimethylamino)phenyl]methylene]cyclohexa-2,5-dien-1-ylidene]dimethylammonium chloride (Basic Blue 26; CI 44045)	2580-56-5
288	4-[(4-Aminophenyl)(4-iminocyclohexa-2,5-dien-1-ylidene)methyl]-o-toluidine and its hydrochloride salt (Basic Violet 14; CI 42510)	632-99-5/ 3248-93-9

編號	成分名	CAS No.
289	2-Chloro-5-nitro-N-hydroxyethyl- p-phenylenediamine and its salts	50610-28-1
290	4,4'-Diaminodiphenylamine and its salts	537-65-5
291	2,4-Diamino-5-methylphenoxyethanol and its salts	141614-05-3/ 113715-27-8
292	N,N-Diethyl-p-phenylenediamine and its salts	6065-27-6/ 6283-63-2/ 93-05-0
293	N,N-Dimethyl-p-phenylenediamine and its salts	99-98-9/ 6219-73-4
294	3-[(2-nitro-4-(trifluoromethyl)phenyl)amino]propane1,2-diol (HC Yellow No. 6) and its salts	104333-00-8
295	2-[(4-chloro-2-nitrophenyl)amino]ethanol (HC Yellow No. 12) and its salts	59320-13-7
296	Hydroxyethyl-2,6-dinitro-p-anisidine and its salts	122252-11-3
297	Hydroxyethylaminomethyl-p-aminophenol and its salts	110952-46-0/ 135043-63-9
298	6-Nitro-2,5-pyridinediamine and its salts	69825-83-8
299	diethylene glycol 化粧品於製造過程中，如因所需使用之原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含二甘醇(diethylene glycol)之殘留量，不得超過 1000ppm。	111-46-6
300	m-Phenylenediamine and its salts	108-45-2/ 541-69-5/ 541-70-8
301	Travamide	-
302	Methyl alcohol 化粧品於製造過程中，如因所需使用之原料或其他因素，且技術上無法避免，致含自然殘留微量時，則其最終製品中所含甲醇 (methyl alcohol) 之殘留量，不得超過 2000ppm。	67-56-1
303	Rhododendrol	69617-84-1
304	Coal tars	8007-45-2
305	Estradiol	50-28-2
306	Estrone	53-16-7
307	Ethinyl estradiol	57-63-6
308	Antihistamine	-
309	Safrole (Shikimol) (黃樟素) 使用樟科等植物原料來源成分者，其最終殘留限量如下： 最終製品中所含黃樟素含量不得超過 100ppm	94-59-7
310	Verbena essential oils (Lippia citriodora Kunth.) (馬鞭草油) (Verbena absolute (Lippia citriodora Kunth.)除外)	8024-12-2
311	Costus root oil (Saussurea lappa Clarke) (木香根油)	8023-88-9
312	Fig leaf absolute (Ficus carica L.) (無花果葉萃取物)	68916-52-9

編號	成分名	CAS No.
313	<i>Alocasia cucullata</i> (Lour.) Schott (薊芥;尖尾姑婆芋)	-
314	<i>Amorphophallus rivieri</i> Durieu (<i>Amorphophallus konjac</i>) (蒟蒻) 經精化、去毒程序而製成之食用蒟蒻除外	-
315	<i>Alocasia macrorrhiza</i> (L.) Schott (<i>Alocasia odora</i> (Roxb.) K. Koch) (海芋;姑婆芋)	-
316	<i>Catharanthus roseus</i> (L.) G. Don (長春花)	-
317	<i>Cerbera manghas</i> L. (牛心茄子)	-
318	<i>Ranunculus</i> L.,(Ranunculaceae) (毛茛科毛茛屬植物)	84929-74-8
319	<i>Crotalaria sessiliflora</i> L. (野百合)	-
320	<i>Dioscorea hispida</i> Dennst. (白薯蕷(大苦薯))	-
321	<i>Gelsemium elegans</i> Benth. (鈎吻)	-
322	<i>Stellera chamaejasme</i> L. (狼毒)	-
323	<i>Anemone hupehensis</i> Lemoine (打破碗花)	-
324	Barium salts 硫酸鋇及色素之不溶性鋇鹽(salts)、麗基(lakes)和顏料(pigments)除外	-
325	Tetrahydrocannabinols 如化粧品中使用大麻籽油(<i>Cannabis sativa</i> seed oil(Hemp seed oil))為原料時,則其最終製品中所含四氫大麻酚(Tetrahydrocannabinols)之殘留量不得超過10ppm。	1972-08-3
326	Nonylphenol and Nonylphenol polyethylene glycol ether 化粧品於製造過程中,如因所需使用之原料或其他因素,且技術上無法避免,致含自然殘留微量時,則其最終製品中所含壬基酚或壬基酚聚乙氧基醇之殘留量,不得超過1000ppm。	25154-52-3
327	Substances with androgenic effect	-
328	2,2,2 -Trichloroethane-1,1-diol	302-17-0
329	N,N-bis(2-Chloroethyl)methylamine N-oxide and its salts	126-85-2
330	Chlormethine (INN) and its salts	51-75-2
331	Cyclophosphamide (INN) and its salts	50-18-0
332	Cobalt benzenesulphonate	23384-69-2
333	Dichloroethanes (ethylene chlorides) e.g. 1,2-Dichloroethane	107-06-2
334	O,O' -Diethyl-O-4-nitrophenyl phosphorothioate	56-38-2
335	Barbiturates	-
336	Metaldehyde	9002-91-9
337	Triamterene (INN) and its salts	396-01-0
338	Thiotepa (INN)	52-24-4
339	Trichlormethine (INN) and its salts	555-77-1/ 817-09-4/ 6138-32-5
340	Furocoumarines (e.g. trioxysalen (INN), 8 -methoxypsoralen, 5-methoxypsoralen) except for normal content in natural essences used. In sun protection and in bronzing products, furocoumarines shall be below 1 mg/kg	298-81-7/ 484-20-8/

編號	成分名	CAS No.
		3902-71-4
341	2,3,7,8-Tetrachlorodibenzo-p-dioxin (TCDD)	1746-01-6
342	1,2-Epoxybutane	106-88-7
343	3,3-Bis(4-hydroxyphenyl)phthalide (Phenolphthalein (INN))	77-09-8
344	Ethyl acrylate, when used as a fragrance ingredient	140-88-5
345	Cobalt sulphate	10124-43-3
346	Nickel monoxide; nickel oxide; bunsenite	1313-99-1/ 11099-02-8/ 34492-97-2
347	Nickel dioxide	12035-36-8
348	Nickel sulfide	16812-54-7
349	Hydrocarbons, C4, 1,3 -butadiene- and isobutene-free, if they contain > 0.1% w/w Butadiene	95465-89-7
350	Benzo[def]chrysene; (=benzo[a]pyrene)	50-32-8
351	Pitch, coal tar, high -temp., heat-treated, if it contains > 0.005% w/w benzo[a]pyrene	121575-60-8
352	Dibenz[a,h]anthracene	53-70-3
353	Benz[a]anthracene	56-55-3
354	Benzo[j]fluoranthene	205-82-3
355	Benz[e]acephenanthrylene	205-99-2
356	Benzo[k]fluoranthene	207-08-9
357	Chrysene	218-01-9
358	2,3-Dibromopropan-1-ol	96-13-9
359	1,3-Dichloropropan-2-ol	96-23-1
360	alpha-Chlorotoluene (Benzyl chloride)	100-44-7
361	Methyloxirane (Propylene oxide)	75-56-9
362	1,2-Epoxy-3-phenoxypropane (Phenylglycidyl ether)	122-60-1
363	2,3-Epoxypropan-1-ol (Glycidol)	556-52-5
364	Urethane (Ethyl carbamate)	51-79-6
365	2-Nitropropane	79-46-9
366	2-Nitroanisole	91-23-6
367	2,4-Dinitrotoluene; Dinitrotoluene, technical grade	121-14-2/ 25321-14-6
368	5-Nitroacenaphthene	602-87-9
369	2,6-Dinitrotoluene	606-20-2
370	1-Methyl-3-nitro-1-nitrosoguanidine	70-25-7
371	4,4'-(4-Iminocyclohexa-2,5-dienylidene)methylene) dianiline hydrochloride	569-61-9/ 479-73-2
372	o-Toluidine based dyes	-

編號	成分名	CAS No.
373	(Methyl-ONN-azoxy)methyl acetate	592-62-1
374	Furan	110-00-9
375	1,3-Propanesultone	1120-71-4
376	Sulfallate	95-06-7
377	Erionite	12510-42-8
378	Disodium 4 -amino-3-[[4'-[(2,4-diaminophenyl)azo] [1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-(phenylazo)naphthalene-2,7-disulphonate	1937-37-7
379	Disodium[5 -[[4'-[[2,6-dihydroxy-3-[(2-hydroxy-5-sulphophenyl)azo]phenyl]azo][1,1'-biphenyl]-4-yl]azo]salicylato(4-)]cuprate(2-)	16071-86-6
380	Resorcinol diglycidyl ether	101-90-6
381	Divanadium pentaoxide	1314-62-1
382	Chlordecone	143-50-0
383	Chlorothalonil	1897-45-6
384	Dodecachloropentacyclo[5.2.1.02,6.03,9.05,8]decane (Mirex)	2385-85-5
385	4,4'-Carbonimidoylbis[N,N-dimethylaniline] and its salts	492-80-8
386	Acetamide	60-35-5
387	1-Vinyl-2-pyrrolidone	88-12-0
388	α , α -Dichlorotoluene	98-87-3
389	Isoprene (stabilized); (2 -Methyl-1,3-butadiene)	78-79-5
390	1-Bromopropane; n-Propyl bromide	106-94-5
391	Chloroprene (stabilized); (2 -Chlorobuta-1,3-diene)	126-99-8
392	4,4'-Bis(dimethylamino)benzophenone; (Michler's ketone)	90-94-8
393	1,4-Dichlorobenzene (p-Dichlorobenzene)	106-46-7
394	Creosote, if it contains > 0.005 % w/w benzo[a]pyrene	8001-58-9
<p>※未經中央主管機關公告或核准得使用於化粧品中之藥品成分(含管制藥品)，均不得摻用。</p> <p>※本表所稱之口腔製劑，包含非藥用牙膏、漱口水類及美白牙齒類等化粧品。</p>		